
Direct Exfoliation of g-C₃N₄ with Addition of NaOH for Enhanced Photocatalytic

Cr(VI) Reduction

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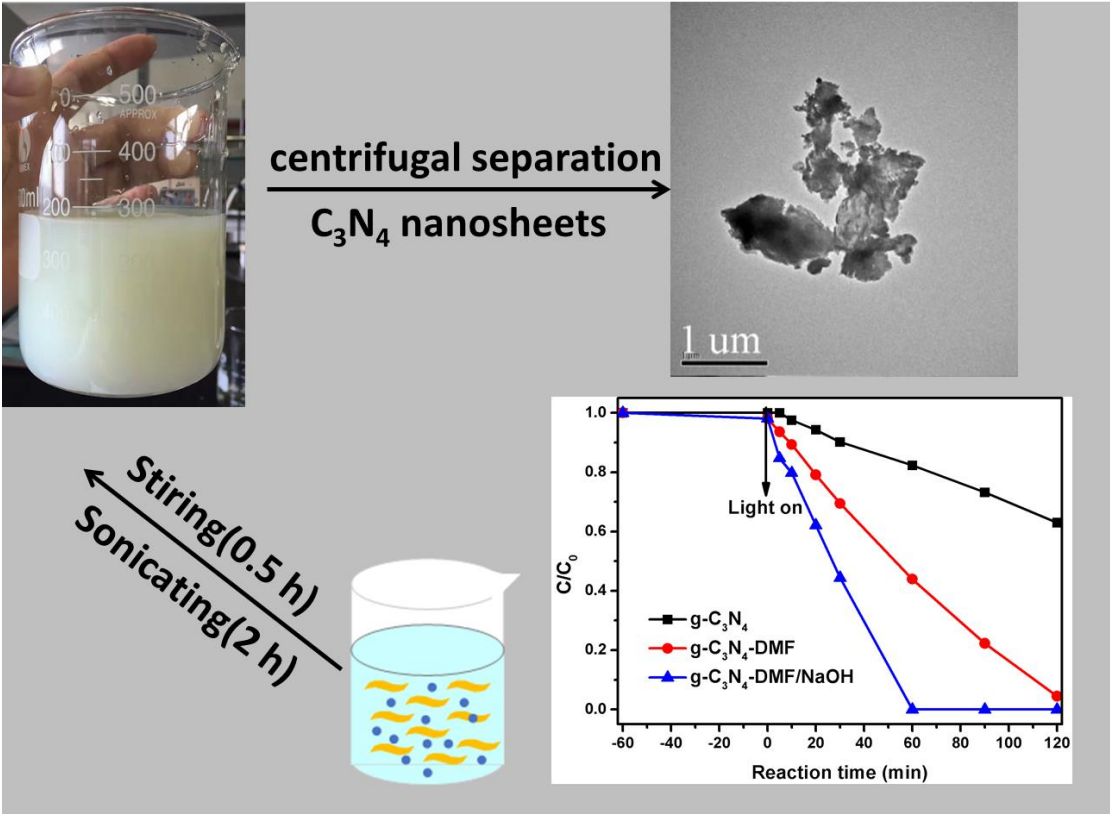
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Abstract

A simple, effective and environmental-friendly method was adopted for enhancing the photocatalytic activity of g-C₃N₄ in the reduction of aqueous Cr(VI) under visible-light irradiation. The enhancement was achieved via treatment of g-C₃N₄ in organic solvent with addition of NaOH particles by ultrasonic process for two hours. The results demonstrated that the treated g-C₃N₄ exhibited much higher photocatalytic activity than pristine g-C₃N₄ in the reduction of Cr(VI). Under visible light irradiation for 120 min, the reduced ratios of Cr(VI) with the initial concentration of 50 mg/L in the presence of the treated g-C₃N₄ and pristine g-C₃N₄ were 100% and 37.1%, respectively. With the addition of fulvic acid, Cr(VI) was efficiently removed at 40 min. Based on the characterization results of the structures and other physiochemical properties of the treated g-C₃N₄ and pristine g-C₃N₄ by X-ray diffraction, scanning electron microscopy, transmission electron microscopy and UV Vis diffuse reflectance, the possible reasons responsible for the enhanced photocatalytic activity of the treated g-C₃N₄ were proposed. The yield and mechanism of different exfoliation methods were compared by semi-quantitative method.

Key words: g-C₃N₄; photocatalysis; NaOH; exfoliation; Cr(VI) reduction

1. Introduction

Graphite-like Carbon nitride (g-C₃N₄) is a metal-free polymer with a band gap of about 2.7 eV. It is nontoxic, stable, and easy synthesized from rich and cheap CN-containing precursor [1]. In addition, it has been proved to have photocatalytic activity responsive to visible light in many chemical reactions [2-7]. Thus, g-C₃N₄ is regarded as a kind of promising photocatalyst for water splitting and degradation of organic pollutants under sunlight irradiation. Bulk g-C₃N₄ synthesized by the traditional thermal condensation polymerization shows low photocatalytic activity for its large particle size, small surface area and high recombination rate of photogenerated carriers[8]. So it is necessary to explore an effective and environmentally friendly method for improving the photocatalytic activities.

Bulk g-C₃N₄ has a layered structure with properties similar to that of graphite in which the C-C bond is replaced by a strong covalent C-N bond, and the layer is connected by a weak van der Waals force. g-C₃N₄ can be easily peeled off into monolayer or layers of nanosheets due to its graphite-like structure. It's reasonable that monolayered g-C₃N₄ nanosheets have excellent photocatalytic properties. For example, Wang firstly stirred it with strong acid (37% HCl) for 3 hours, reporting a reversible protonation of carbon nitride [7]; Liu and his colleagues developed a heat treatment to reduce its size [9]. From these results, the treated C₃N₄ showed much higher photocatalytic activities than the bulk g-C₃N₄ under visible light irradiation.

Notably, this method still has some disadvantages, such as the formation of the interface defects during the calcination process, the reduction of the photo absorption ability, the relatively thick nanosheet, and the poor yield (< 6%). These disadvantages for the photocatalytic reaction are critical. Although the exfoliation of high quality C_3N_4 2D nanosheets with low defects could also be achieved mechanically on a small scale, a simple liquid exfoliation method would allow the formation of 2D nanosheets in large quantities. Inspired by the graphene stripping method, some researchers have developed some liquid stripping methods to fabricate few-layered C_3N_4 nanosheets [10,11]. Unfortunately, the concentration of the as-prepared C_3N_4 nanosheets suspension is very low (nanosheets μ g/mL [11], and the monolayered nanosheet is limited [10], and the atomic structure of the plane during stripping maybe also seriously damage. Therefore, it's desired to develop a novel, facile, and rapid route to fabricate the C_3N_4 nanosheets.

In order to develop a simple, environmentally friendly and high-yield stripping method, NaOH were added into the organic solvent for liquid exfoliation of bulk g- C_3N_4 to produce monolayered C_3N_4 nanosheets for the first time, which improved the original liquid exfoliation process. On the basis of this, The photocatalytic activities of the untreated C_3N_4 and C_3N_4 nanosheets were compared by the reduction of Cr(VI) under visible-light (effect of exfoliation of bulk g- C_3N_4 on the reduction of organic acid. Moreover, the possible reasons responsible for the enhanced photocatalytic activity of the treated g- C_3N_4 were proposed based on the characterization results of the structures and other physiochemical properties of

untreated C_3N_4 and C_3N_4 nanosheets.

2. Experiment Section

2.1 Preparation of g- C_3N_4 nanosheets

The bulk g- C_3N_4 was prepared by polymorization of melamine molecules in a muffle furnace, melamine was heated at 600°C for 4 h under air condition with a ramp rate of about 2.3°C/min in detail. The ultrathin g- C_3N_4 nanosheets were obtained by liquid exfoliating of as-prepared bulk g- C_3N_4 in organic solvent (DMF). In detail, 300 mg of untreated C_3N_4 was added into 250 ml of DMF and 50 mg of sodium hydroxide (NaOH) was added, and then sonicated for 2 h after magnetic stirring, the resulting solution was centrifuged and the supernatant was dried in air at a constant temperature, referred to as g- C_3N_4 -DMF/NaOH. g- C_3N_4 -DMF was obtained without the addition of NaOH for comparison.

2.2 Characterization of g- C_3N_4 nanosheets

The microstructure of g- C_3N_4 was characterized by field emission scanning electron microscopy (SEM, SU-8020, Hitachi, Japan) and transmission electron microscopy (TEM, H-7500, Hitachi, Japan). The crystal structure and functional groups were X-ray diffraction (XRD, X'Pert PRO MPD, Netherlands Panako Analytical Instruments Co., Ltd.) and UV-Vis diffuse reflectance spectroscopy (UV-VIS, Nicolet 8700, Thermo Fisher Scientific).

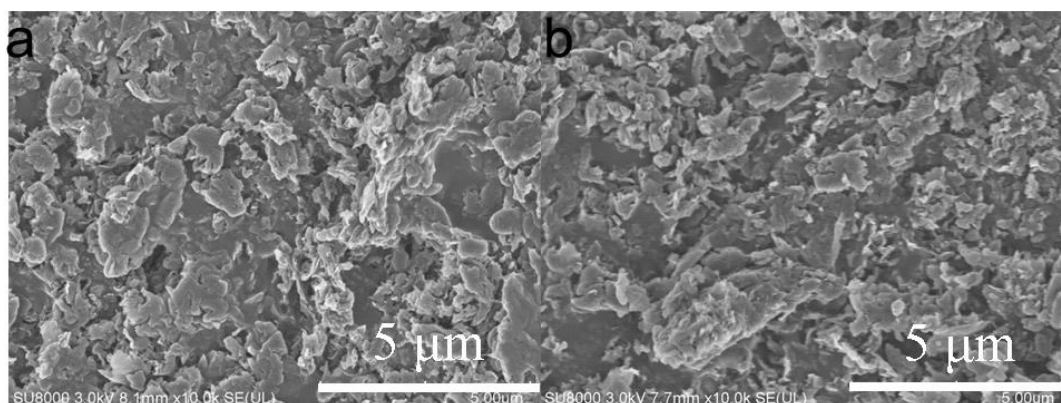
Photocatalytic activities of the samples (60 mg) were tested by the reduction of Cr(VI) with the initial concentration of 100 mg/L $K_2Cr_2O_7$ aqueous solution under

visible-light (aqueous solution irradiation, with the addition of 1.0 mL of 100 mg/mL organic acid solution (citric acid, fulvic acid, oxalic acid) as sacrificing reagent. The concentration of Cr(VI) was measured by using diphenyl carbazide spectrophotometry (GB 7467-87).

3. Results and Discussion

3.1 Characterization of physiochemical properties of g- C_3N_4 nanosheets

Fig. 1 and 2 showed the SEM images of g- C_3N_4 obtained from different methods at different magnification. g- C_3N_4 -DMF/NaOH sample still maintained loose and irregular tissue-like 2D nanosheet morphology at different magnification (Fig. 1c, Fig. 2), although a small portion of C_3N_4 nanosheets was stacked. Its morphology was quite different from that of the untreated g- C_3N_4 with a typical layer structure stacked layer by layer (Fig. 1a), g- C_3N_4 -DMF had a thicker layered structure and more layers was stacked without the addition of NaOH.



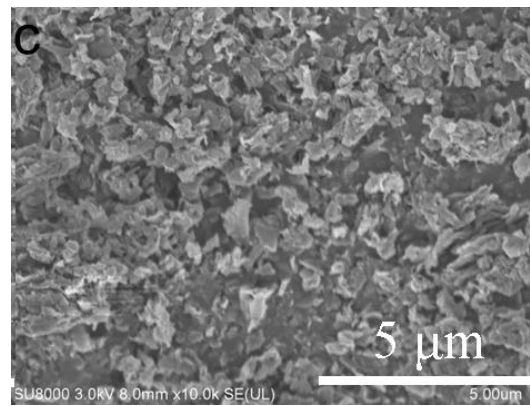


Fig. 1 SEM image of (a) g-C₃N₄ (b) g-C₃N₄-DMF; (c) g-C₃N₄-DMF/NaOH.

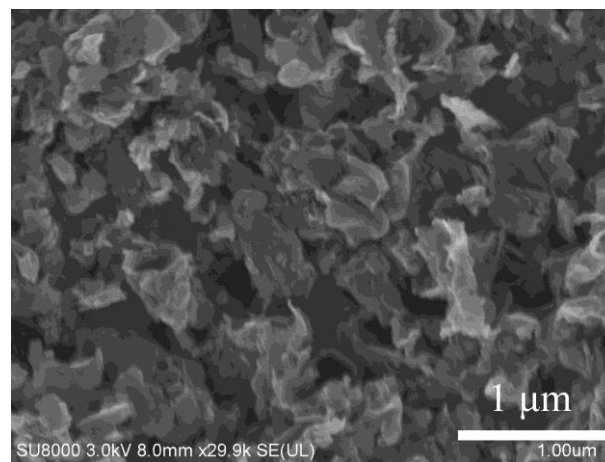


Fig. 2 SEM image of g-C₃N₄-DMF/NaOH-1 μm.

Fig. 3 showed the TEM images of g-C₃N₄-DMF/NaOH and g-C₃N₄-DMF. At different magnifications (1 μm, 0.5 μm and 0.2 μm), TEM images show that the as-prepared C₃N₄ (g-C₃N₄-DMF/NaOH) with laminar morphology exhibited nearly transparent feature, indicating its ultrathin thickness. Its lateral scale ranged from sub-micrometer to several micrometers. The horizontal scale range was about 3-4 μm. There are no obvious layered structure and obvious shadows observed at g-C₃N₄-DMF (Fig.3d, e, f). Smaller particle sizes mean that their photogenerated electrons and holes move from the site to the solid-liquid interface at a shorter distance, thereby reducing the recombination probability of their photogenerated carriers. [12,13]

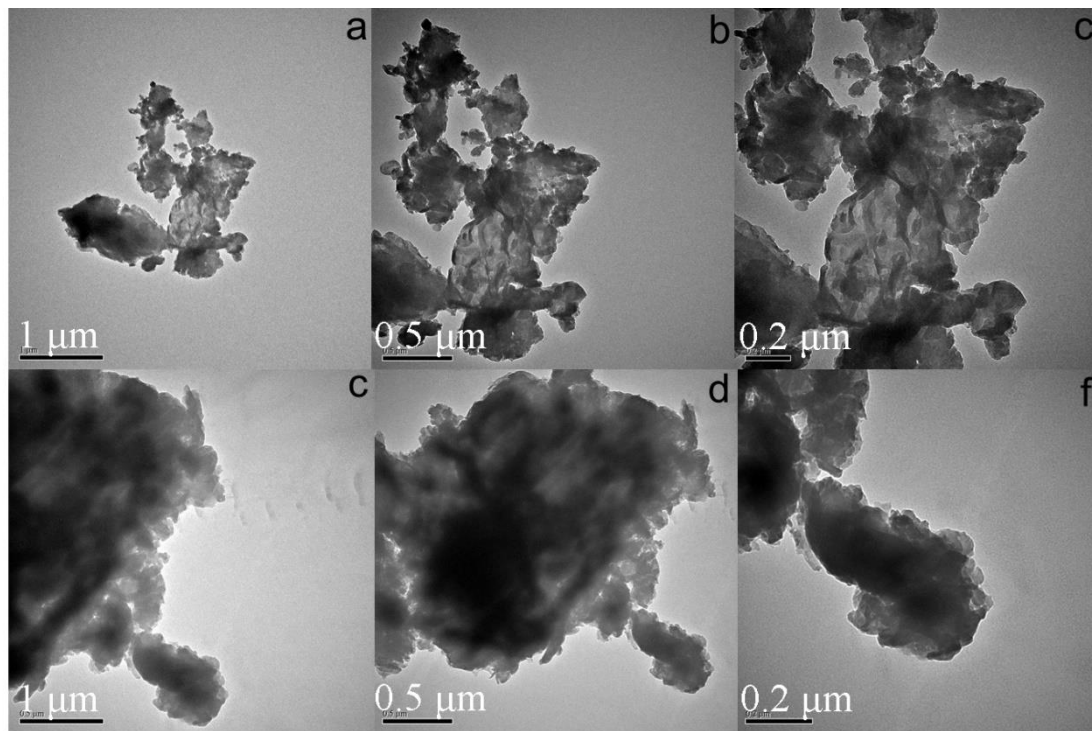


Fig. 3 TEM image of (a) g-C₃N₄-DMF/NaOH-1 μm; (b) g-C₃N₄-DMF/NaOH-0.5 μm; (c) g-C₃N₄-DMF/NaOH-0.2 μm; (d) g-C₃N₄-DMF -1 μm; (e) g-C₃N₄-DMF -0.5 μm; (f) g-C₃N₄-DMF -0.2 μm.

The ultra-thin thickness of g-C₃N₄-DMF/NaOH was further verified by the AFM image. As shown in Fig. 4, the representative AFM image shows a uniform thickness of about 0.38 nm. This thickness agrees well with the theoretical values of single-layer carbon nitride (0.324 nm) [14,15]. This can be used as a strong evidence for the presence of g-C₃N₄ nanosheets in the presence of monatomic layers in mixed solvents.

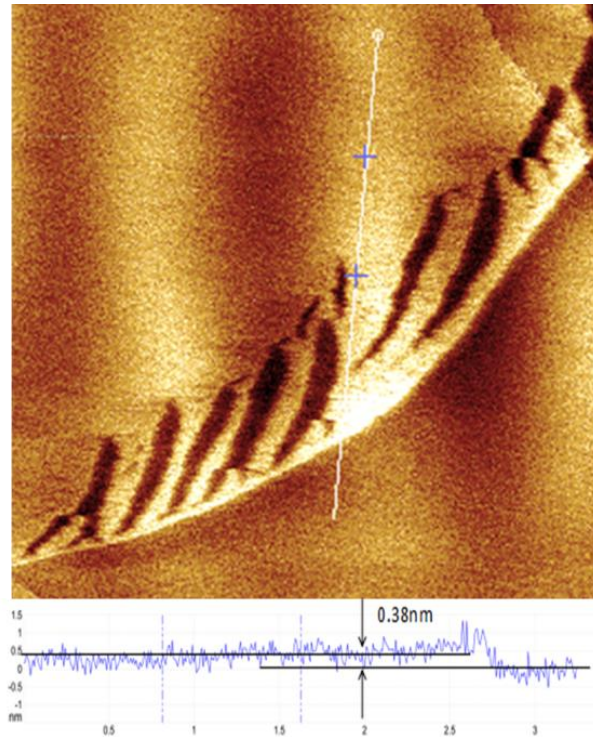


Fig. 4 AFM image of g-C₃N₄-DMF/NaOH.

Fig. 5 showed the XRD patterns of g-C₃N₄ nanosheets. It can be seen from the figure that the g-C₃N₄ nanosheet exhibits two distinct diffraction peaks at 13.2 ° and 27.3 °. The diffraction peak at 13.2 ° corresponds to the (100) crystal plane of g-C₃N₄ with the interplanar spacing of 0.676 nm, the 3-s-triazine ring structure of g-C₃N₄; the diffraction peak at 27.3 ° corresponds to g (002) crystal plane with the interplanar spacing of 0.324 nm, which is the accumulation of g-C₃N₄ aromatic structure, corresponding to the layer spacing of g-C₃N₄ [16]. As shown in the figure, the peak height of the diffraction peak at 27.3 ° decreases gradually from bottom to top, indicating that the intergranular stacking structure of g-C₃N₄ and the periodic arrangement of the layers are destroyed, indicating that g-C₃N₄ of is successfully stripped [12].

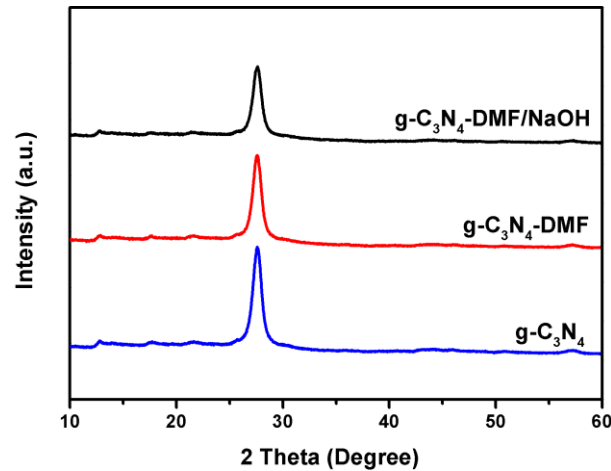


Fig. 5 XRD results of the g-C₃N₄ samples.

Fig. 6a showed the UV-Vis diffuse spectrum of g-C₃N₄. A typical semiconductor absorption, photogenerated electron transfers from the valence band (VB) level formed by the N 2p orbit to the conduction band (CB) level formed by the C 2p orbit under irradiation, the absorption of as-prepared C₃N₄ in the visible region is significantly improved and exhibits a significant absorption boundary displacement. The absorption thresholds λ_g of g-C₃N₄, g-C₃N₄-DMF and g-C₃N₄-DMF/NaOH were 461, 472 and 494 nm, respectively. Using the formula $[\alpha h\nu]^n = A(h\nu - E_g)$ to calculate the band gap width E_g of g-C₃N₄, g-C₃N₄-DMF and g-C₃N₄-DMF/NaOH, where α is the absorption coefficient; $h\nu$ is the photon energy and is a constant; E_g is the required band gap Width (optical bandgap); n is determined by the basic properties of the semiconductor ($n = 2$) [16,17]. The results are shown in Fig 6b, which are 2.53, 2.51, 2.44 eV, respectively. The results show that the addition of NaOH can change the band structure of g-C₃N₄, reduce the bandgap energy and improve the utilization rate of visible light.

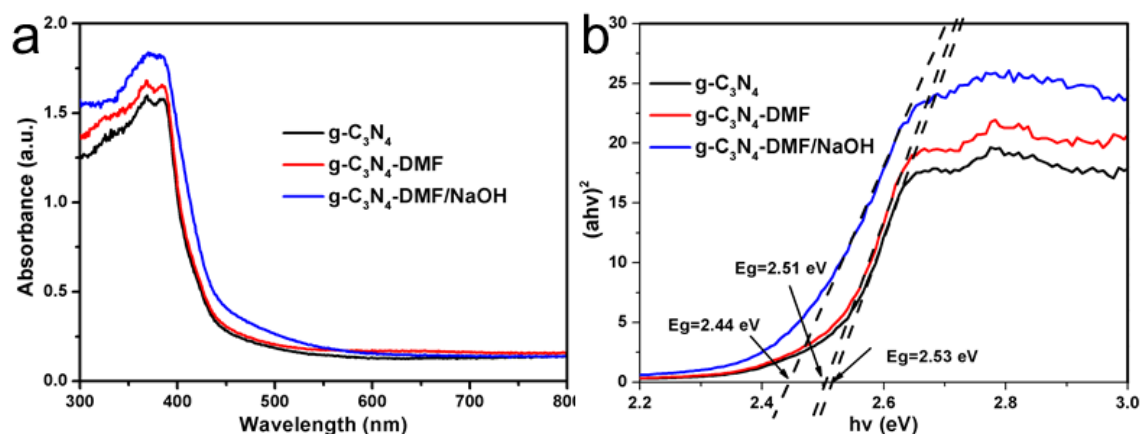


Fig. 6 UV-vis DRS spectra of g-C₃N₄.

3.2 Photocatalytic reduction of Cr(VI) by g-C₃N₄

As shown in Fig.7a, the removal efficiency of Cr(VI) is 37.1%, 95.5%, 100%, respectively, and the sequence of photocatalytic reduction activity is g-C₃N₄-DMF/NaOH > g-C₃N₄-DMF > g-C₃N₄; Cr(VI) can be completely removed in 60 min with g-C₃N₄-DMF/NaOH. g-C₃N₄ treated with NaOH shows the highest photocatalytic activity. In the initial 60 min string in dark, there is no change in the morphology of C₃N₄ after stripping, and the removal rate (adsorption) of Cr(VI) is almost ignored. Fig.7b shows the removal rate of Cr(VI) by photocatalytic reduction using the g-C₃N₄-DMF/NaOH samples with different organic acids as sacrificing reagent. The removal rate of Cr(VI) is almost ignored with organic acids (citric acid, fulvic acid, oxalic acid) alone. After the addition of the treated g-C₃N₄ nanosheets, Cr(VI) could be completely removed within 120 min (60 min, 40 min, 120 min, respectively). The removal rate is related to the ability of different organic acids to capture the hole. The experimental results show that g-C₃N₄-DMF/NaOH samples can effectively remove Cr(VI) with different organic acids.

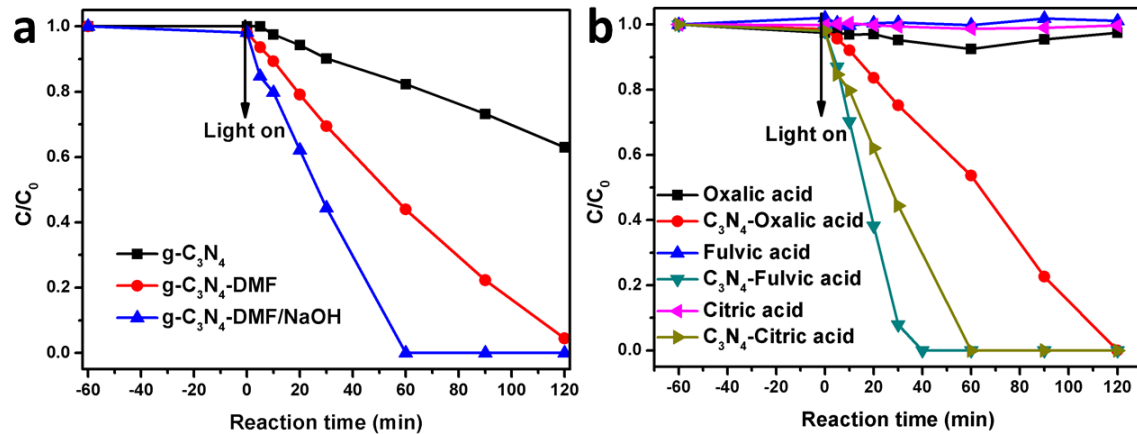


Fig. 7 (a) the photocatalytic reduction of Cr(VI) using different samples; (b) the effect of organic acids on the photocatalytic reduction of Cr(VI); Cr(VI) initial concentration: 50 mg/L; organic acid concentration: 1 mg/L; 300 mW Xe lamp; $\lambda > 400$ nm).

3.3 $g-C_3N_4$ nanosheet production and exfoliation mechanism

Fig. 8 shows the $g-C_3N_4$ nanosheet suspension (3000 rpm low-speed centrifuged supernatant) with different exfoliation methods. For the convenience of description, the products obtained in DMF or IPA were recorded as $g-C_3N_4$ -DMF, $g-C_3N_4$ -IPA and so on. As shown in the right-hand centrifuge tube of Figure 8a, the $g-C_3N_4$ nanosheets were dispersed to a maximum concentration, showing milky white (about 1.2 mg/ml). In contrast, pure DMF stripping showed a relatively low concentration (Figure 8a, left), showing a pale white (about 0.3 mg/ml). The experimental results showed that the addition of NaOH increased the yield of $g-C_3N_4$ nanosheets. This phenomenon verifies a fact that dispersed concentration is maximized when the energy of exfoliation is minimized. The energy of the exfoliation can be expressed by the enthalpy of mixing (ΔH_{mix} , unit volume), calculated from the empirical formula shown below (Eq 1) [18,19]:

$$\frac{\Delta H_{\text{mix}}}{V_{\text{mix}}} \approx \frac{2}{T_{\text{nanosheet}}} (\delta_{\text{nanosheet}} - \delta_{\text{solvent}})^2 \phi \quad \text{Eq 1}$$

Where V is the volume of the suspension, δ is the square root of the surface energy, T is the average thickness of the nanosheets, and ϕ is the volume fraction of the nanosheets. The Hildebrand-Scratchard formula indicates that the enthalpy of mixing is dependent on the surface energy balance of C_3N_4 and solvent. For C_3N_4 , the surface energy can be defined as the energy per unit area to overcome the energy required for the van der Waals force to separate the two pieces.

From the formula, we hope that the surface energy (δ_{solvent}) of the solvent matches the surface energy of the carbon nitride ($\delta_{\text{nanosheet}}$) and obtain more nanosheets at the minimum energy cost. For a mixed system, the surface energy can be adjusted by simply changing their composition. In this case, NaOH is not soluble in DMF, but it effectively changes its surface energy, thereby increasing the yield of g- C_3N_4 nanosheets, which is consistent with the literature [20].

As shown in Figure 8a, b, c, we also studied the effect of NaOH on the yield of g- C_3N_4 nanosheets for several other organic solvents. The centrifugal tubes on the left side of each panel were centrifuged at 3000 rpm without adding NaOH, the right side of the supernatant is the one with the addition of NaOH. From the figure it is clearly seen the left side of the clarity in the clear, the right side of the milky white. After the collection, it was found that the addition of NaOH in different organic solvents for g- C_3N_4 nanosheet stripping could increase the yield, which was consistent with the results of the addition of NaOH in the organic solvent to increase the yield of

graphene nanosheets[20].

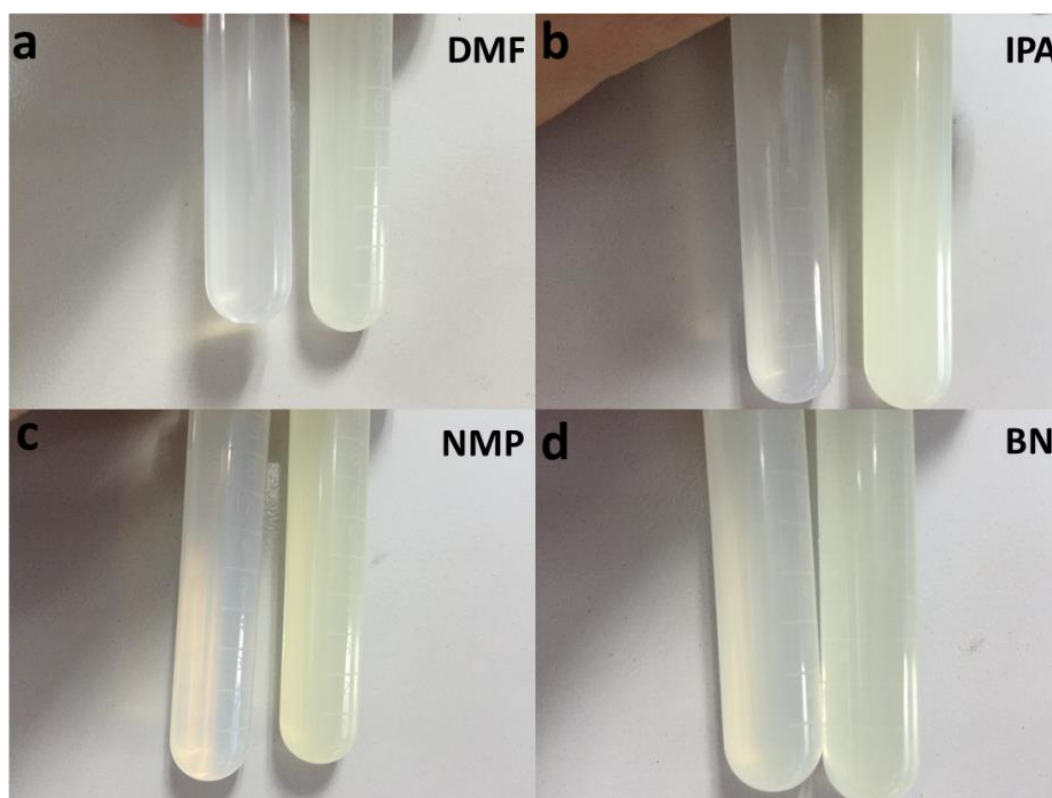


Fig. 8 C₃N₄ sheets dispersed in organic solvents with or without addition of NaOH.

4. Conclusions

In conclusion, monolayer C₃N₄ nanosheets have been successfully prepared by a new, simple solvent intercalation method. The poor solvent could be changed into good solvent by adding NaOH particles for efficiently exfoliating bulk g-C₃N₄ into C₃N₄ nanosheets. Importantly, the concentration of C₃N₄ nanosheets could be increased for 4 times by simply adding NaOH particles into the solvent. The as-prepared C₃N₄ nanosheets with monolayer thickness would be endowed a new band structure and superior photocatalytic properties, such as favorable band structure, higher visible light absorption efficiency, lower photo-generated electron-hole pair recombination efficiency, higher specific surface area, and low surface defects. More

intuitive to say, the high degradation efficiency of Cr(VI) was obtained by the as-prepared C₃N₄ nanosheets. The removal efficiency of Cr(VI) is twice as high as that of g-C₃N₄-DMF, which is 6 times for bulk g-C₃N₄. g-C₃N₄-DMF/NaOH can be directly added to the organic acid leaching Cr(VI) wastewater for photocatalytic reaction, Cr(VI) can be completely removed (120 min) under three different organic acid conditions.

Acknowledgements

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